

# US Patent & Trademark Office

## Patent Public Search | Text View

---

United States Patent	12388413
Kind Code	B2
Date of Patent	August 12, 2025
Inventor(s)	Lin; Shih-Meng et al.

---

### Acoustic wave device with enhanced quality factor and fabrication method thereof

---

#### Abstract

An acoustic wave device includes a piezoelectric substrate, a transducer, and a depression. The transducer is disposed on a surface of the piezoelectric substrate, and includes a first bus bar, a first electrode, a second bus bar, and a second electrode. The first bus bar and the second bus bar extend along a second direction. The first electrode has a first end and extends from the first bus bar along a first direction. The first electrode and the second electrode are spaced apart from each other, and a gap is formed between the first end of the first electrode and an edge of the second bus bar. The depression is formed in the piezoelectric substrate and is depressed from the surface of the piezoelectric substrate. The first end of the first electrode is continuously joined to a sidewall of the depression along a depth direction.

---

<b>Inventors:</b>	Lin; Shih-Meng (Taipei, TW), Chen; Shih-Che (Taipei, TW)
<b>Applicant:</b>	RichWave Technology Corp. (Taipei, TW)
<b>Family ID:</b>	1000008752049
<b>Assignee:</b>	RichWave Technology Corp. (Taipei, TW)
<b>Appl. No.:</b>	17/842801
<b>Filed:</b>	June 17, 2022

#### Prior Publication Data

<b>Document Identifier</b>	<b>Publication Date</b>
US 20230344402 A1	Oct. 26, 2023

#### Foreign Application Priority Data

TW	111115146	Apr. 21, 2022
----	-----------	---------------

---

## Publication Classification

**Int. Cl.:** H03H9/02 (20060101)

**U.S. Cl.:**

**CPC** H03H9/02574 (20130101); H03H9/02992 (20130101);

## Field of Classification Search

**CPC:** H03H (9/02157); H03H (9/02574); H03H (9/02622); H03H (9/02858); H03H (9/02881); H03H (9/02992)

---

## References Cited

### U.S. PATENT DOCUMENTS

Patent No.	Issued Date	Patentee Name	U.S. Cl.	CPC
6516503	12/2002	Ikada	N/A	N/A
7112860	12/2005	Saxler	N/A	N/A
10958236	12/2020	Li	N/A	H03H 9/02228
2021/0091747	12/2020	Turner	N/A	H03H 9/173

### FOREIGN PATENT DOCUMENTS

Patent No.	Application Date	Country	CPC
114208036	12/2021	CN	N/A
200511714	12/2004	TW	N/A
202103345	12/2020	TW	N/A
202125972	12/2020	TW	N/A

### OTHER PUBLICATIONS

Notice of Allowance mailed on Jan. 11, 2023 for the Taiwan application No. 111115146, filing date Apr. 21, 2022, pp. 1-6. cited by applicant

---

*Primary Examiner:* Desai; Naishadh N

---

## Background/Summary

### TECHNICAL FIELD

(1) The present invention relates to radio frequency communication, and in particular, to an acoustic wave device with enhanced quality factor in radio frequency communication and a fabrication method thereof.

### BACKGROUND

(2) A surface acoustic wave (SAW) device may be used for converting and transmitting electrical signals and acoustic signals. The SAW filters are used in many applications. For example, the SAW filters can filter out noise and reserve wireless signals in the desired frequency bands, offering a low transmission loss and excellent performance in anti-electromagnetic interference while being compact in size, and thus providing wide uses in various communication products. However,

conventional SAW filters may suffer from energy leakage, resulting in degradation in quality factor. In addition, the SAW filters can also serve as resonators.

## SUMMARY

(3) According to an embodiment of the invention, an acoustic wave device includes a piezoelectric substrate having a first surface, a transducer disposed on the first surface of the piezoelectric substrate, and a first depression formed in the piezoelectric substrate and depressed from the first surface of the piezoelectric substrate. The transducer includes a first bus bar extending along a second direction, a first electrode having a first end and extending from the first bus bar to the first end along a first direction, a second bus bar extending along the second direction, and a second electrode having a second end and extending from the second bus bar to the second end along the first direction. The second electrode and the first electrode may be spaced apart in the second direction, and a first gap may be formed between the first end of the first electrode and an edge of the second bus bar. The first depression has a first sidewall, and the first end of the first electrode is continuously joined to the first sidewall of the first depression in a depth direction.

(4) According to another embodiment of the invention, a method of fabricating an acoustic wave device includes providing a piezoelectric substrate having a first surface, forming a conductive layer on the first surface, and patterning the conductive layer to form a patterned conductive layer. The patterned conductive layer includes a first bus bar extending along a second direction, a first electrode having a first end extending from the first bus bar to the first end along a first direction, a second bus bar extending along the second direction, and a second electrode having a second end and extending from the second bus bar to the second end along the first direction. The second electrode and the first electrode may be spaced apart in the second direction, and a first gap may be formed between the first end of the first electrode and an edge of the second bus bar. The method further includes forming a first depression in the piezoelectric substrate, the first depression is depressed from the first surface of the piezoelectric substrate, and the first depression includes a first sidewall. The first end of the first electrode may be continuously joined to the first sidewall of the first depression in a depth direction.

---

## Description

### BRIEF DESCRIPTION OF THE DRAWINGS

- (1) FIG. 1 is a top view of an acoustic wave device according to an embodiment of the invention.
- (2) FIGS. 2A to 2C show cross-sectional views of the acoustic wave device in FIG. 1 along Line 2-2'.
- (3) FIG. 3 is a schematic diagram of the depression in the acoustic wave device in FIG. 1 according to another embodiment of the invention.
- (4) FIGS. 4A to 4C show cross-sectional views of the acoustic wave device in FIG. 1 along Line 4-4'.
- (5) FIG. 5 is a top view of an acoustic wave device according to another embodiment of the invention.
- (6) FIGS. 6 to 8 show schematic diagrams of a method of fabricating an acoustic wave device.
- (7) FIG. 9 is a flowchart of the method of fabricating the acoustic wave device.

### DETAILED DESCRIPTION

(8) Below, exemplary embodiments will be described in detail with reference to accompanying drawings so as to be easily realized by a person having ordinary knowledge in the art. The inventive concept may be embodied in various forms without being limited to the embodiments set forth herein. Descriptions of well-known parts are omitted for clarity, and like reference numerals refer to like elements throughout.

(9) FIG. 1 is a top view of an acoustic wave device 1 according to an embodiment of the invention.

In some embodiments, the acoustic wave device **1** may be a surface acoustic wave (SAW) filter. For example, the acoustic wave device **1** may receive an RF signal transmitted from an antenna, convert the RF signal into an acoustic wave, process the acoustic wave to generate a filtered signal, and output the filtered signal. The RF signal and the filtered signal are electrical signals. The applications of the SAW device **1** are not limited to the embodiments of the disclosure, and may also be used in other applications.

(10) In some embodiments, the acoustic wave device **1** may include a piezoelectric substrate **10** and a transducer **11** disposed on the surface of the piezoelectric substrate **10**. The piezoelectric substrate **10** may include a substrate and a piezoelectric material layer disposed on the substrate. For example, the substrate of the piezoelectric substrate **10** may include a silicon substrate. The piezoelectric material layer may include piezoelectric single crystals, piezoelectric polycrystals (including piezoceramics), piezoelectric polymers, and piezoelectric composite materials. For example, the piezoelectric material layer may include zinc oxide (ZnO), aluminum nitride (AlN), lithium tantalate (LiTaO.sub.3) and any combination thereof. The transducer **11** may include a metallic material, and the metallic material may include molybdenum (Mo), copper (Cu), aluminum (Al), gold (Au), platinum (Pt), tungsten (W), and any combination thereof.

(11) In some embodiments, the transducer **11** may be disposed on the surface **101** of piezoelectric substrate **10** and may include bus bar **121**, electrodes **131-133**, bus bar **122**, and electrodes **141-143**. As shown in FIG. 1, the bus bar **121** may extend along the direction D2. The electrodes **131** to **133** have ends **131e** to **133e**, respectively, and may extend from the bus bar **121** respectively to the ends **131e** to **133e** along the direction D1. Similarly, the bus bar **122** may extend along the direction D2. The electrodes **141** to **143** have ends **141e** to **143e**, respectively, and may extend from the bus bar **122** respectively to the ends **141e** to **143e** along the direction D1. The electrodes **141** to **143** are spaced apart from the electrodes **131** to **133** along the direction D2, respectively. For example, the electrode **141** is spaced apart from the electrode **131** along the direction D2. The electrodes **131** to **133** may be parallel to the electrodes **141** to **143**, and the bus bar **121** may be parallel to the bus bar **122**. In the embodiment, the direction D2 may be, but is not limited to, perpendicular to the direction D1, and both the direction D1 and the direction D2 are parallel to the surface **101** of the piezoelectric substrate **10**. In other embodiments, an angle other than 90 degrees may be formed between the direction D2 and the direction D1.

(12) In some embodiments, first gaps may be formed between the ends **131e** to **133e** of the electrodes **131** to **133** and the edge **122e** of the bus bar **122**, respectively. Second gaps may be formed between the ends **141e** to **143e** of the electrodes **141** to **143** and the edge **121e** of the bus bar **121**, respectively. The first gaps may have identical or different size(s) along the direction D1, and/or the second gaps may have identical or different size(s) along the direction D1. For example, the ends **131e-133e** may be aligned with each other along direction D2, and/or the ends **141e-143e** may be aligned with each other along direction D2.

(13) The bus bar **121** and the electrodes **131** to **133** may form a first set of interdigital structures, the bus bar **122** and the electrodes **141** to **143** may form a second set of interdigital structures, and the first set of interdigital structures and the second set of interdigital structures may be arranged interdigitally. In some embodiments, the materials of the electrodes **131** to **133**, the electrodes **141** to **143**, the bus bar **121**, and the bus bar **122** include a metal, and the metal may be selected from at least one of the following: molybdenum (Mo), copper (Cu), aluminum (Al), gold (Au), platinum (Pt), tungsten (W), and a combination thereof.

(14) In some embodiments, the transducer **11** may function as an input transducer or an output transducer. Taking the input transducer as an example, the electrical signal may be input via the bus bar **121/122**, and may be converted into an acoustic signal by the piezoelectric substrate **10** and the electrodes **131**, **141**, **132**, **142**, **133**, and **143** thereon. The acoustic signal may propagate along the direction D2. In other embodiments, the transducer **11** may also be used as an output transducer for converting an acoustic signal into an electrical signal. The ends **131e** to **133e** may be aligned along

the direction D2 and the ends **141e** to **143e** may be aligned along the direction D2. An imaginary line connecting the aligned ends **131e** to **133e** and another imaginary line connecting the aligned ends **141e** to **143e** may be used to define an effective transmission area for the acoustic signal. Specifically, taking the directions shown in FIG. 1 as an example, the imaginary line connecting the ends **131e**, **132e**, and **133e** may be regarded as the first boundary of the effective transmission area for the acoustic signal, and the imaginary line connecting the ends **141e**, **142e**, and **143e** may be regarded as the second boundary of the effective transmission area. In some embodiments, the SAW device **1** may operate in a piston mode, such that energy may not leak or may leak insignificantly through, for example, first gaps between electrodes **131** to **133** and the bus bar **122**, and/or second gaps between the electrodes **141** to **143** and the bus bar **121**.

(15) FIGS. 2A to 2C show cross-sectional views of the acoustic wave device **1** along Line 2-2'. Referring to FIG. 1 and FIG. 2A, in some embodiments, the acoustic wave device **1** may further include a depression **21** positioned corresponding to the first gap between the electrode **131** and the bus bar **122**. Further, the depression **21** may be positioned corresponding to the first gap between the end **131e** of the electrode **131** and the edge **122e** of the bus bar **122**. In FIG. 2A, the depression **21** may be formed in the piezoelectric substrate **10** and depressed, for example, along the direction D3, from the surface **101** of the piezoelectric substrate **10**. The depression **21** has a first sidewall **w1** and a second sidewall **w2**. In the direction D3, the end **131e** of the electrode **131** is continuously joined to the first sidewall **w1** of the depression **21**. Further, the edge **122e** of the bus bar **122** may be continuously joined to the second sidewall **w2** of the depression **21**. Similar to the depression **21**, the acoustic wave device **1** may further include depressions **22** to **23**, and the depressions **22** to **23** may be positioned corresponding to the first gaps between the ends **132e** to **133e** of the electrodes **132** to **133** and the edge **122e** of the bus bar **122**, respectively. Each of the depressions **22** to **23** may be formed in the piezoelectric substrate **10** and depressed from the surface **101** of the piezoelectric substrate **10**, for example, in the direction D3.

(16) In FIG. 1, the acoustic wave device **1** may further include depressions **31** to **33** corresponding to the second gaps between the electrodes **141** to **143** and the bus bar **121**, respectively. The configurations of the depressions **31** to **33** may be similar to those of depressions **21** to **23** with the difference in that the depressions **31** to **33** are positioned corresponding to the second gaps between the ends **141e** to **143e** of the electrodes **141** to **143** and the edge **121e** of the bus bar **121**, respectively. For example, the depression **31** may have a third sidewall and a fourth sidewall. In the direction D3, the end **141e** of the electrode **141** may be continuously joined to the third sidewall of the depression **31**. Further, the edge **121e** of the bus bar **121** may be continuously joined to the fourth sidewall of the depression **31**. In the embodiment, the direction D3 may be perpendicular to the direction D1 and the direction D2.

(17) Referring to FIG. 1 and FIG. 2A, in some embodiments, the acoustic wave device **1** may further include a metal fill **151**. In FIG. 2A, the metal fill **151** may be filled in the depression **21** of the piezoelectric substrate **10**, and the metal fill **151** may have a metal fill surface **1511** and a metal fill bottom **1512**. A distance between the surface **101** and the metal fill surface **1511** along the direction D3 is referred to as **d1**. Furthermore, a thickness between the metal fill surface **1511** and the metal fill bottom **1512** is referred to as **d2**, and the distance **d1** and the thickness **d2** are greater than zero. In FIG. 1, similar to the metal fill **151**, the acoustic wave device **1** may further include metal fills **152** to **153** filled in the depressions **22** to **23**, respectively. Further, the acoustic wave device **1** may include metal fills **161** to **163** filled in the depressions **31** to **33**, respectively. In some embodiments, the arrangement of the metal fills **152** to **153**, **161** to **163** with respect to the depressions **22** to **23**, **31** to **33**, respectively, may be similar to the arrangement of the metal fill **151** with respect to the depression **21**, and the explanation therefor is not repeated here for brevity.

(18) In the embodiments, the transducer **11** and the metal fill may contain the same or different metals. For example, the metal fills **151** to **153** and **161** to **163** may include metals, and the metals may be selected from at least one of the following: molybdenum (Mo), copper (Cu), aluminum

(Al)), gold (Au), platinum (Pt), tungsten (W), and a combination thereof. In such cases, the material density of the metal fill may be greater than that of the piezoelectric substrate **10**, that is, the weight of the metal fill may be greater than that of the piezoelectric substrate **10** of the same volume. Therefore, the metal fills **151** to **153** and **161** to **163** in the depressions **21** to **23** and **31** to **33** may form weight loads at the ends of the electrodes. When the acoustic wave device **1** is in operation, the weight loads formed by the metal fills in the depressions **21** to **23** and **31** to **33** may block the prorogation of the acoustic signal along the direction **D1** (that is, reducing or stopping the prorogation of the acoustic signal along the direction **D1**), thus reducing or eliminating the energy leakage of the acoustic signal through the first gaps or the second gaps, such that most or all the energy of the acoustic signal may be transmitted along the direction **D2**. Therefore, the quality factor (**Q**) of the acoustic wave device **1** is enhanced.

(19) The configuration of the metal fill **151** and the depression **21** are explained in detail in the subsequent paragraphs. The configuration of other metal fills and depressions may be similar to the metal fill **151** and the depression **21**, and explanation therefor will be omitted for brevity. In some embodiments, the first gap formed between the end **131e** of the electrode **131** and the edge **122e** of the bus bar **122** has a top size **d3** along the direction **D1**, and the depression **21** has a bottom size **d4** along the direction **D1**. The ratio of the top size **d3** of the first gap to the bottom size **d4** of the depression **21** may be between 0.8 and 1.2. FIG. 2A shows that the ratio of the top size **d3** of the first gap to the bottom size **d4** of the depression **21** may be substantially equal to 1, that is, the top size **d3** of the first gap is substantially equal to the bottom size **d4** of the depression **21**. In such a case, the first gap and the depression **21** may have a rectangular profile. However, the profiles are not such limited. In some embodiments, as in FIG. 2B, the ratio of the size **d3** to the size **d4** is approximately equal to 1.2. In such a case, the first gap and the depression **21** may have a profile of an inverted trapezium. In FIG. 2C, the ratio of size **d3** to size **d4** is approximately equal to 0.8. In such a case, the first gap and the depression **21** may have a profile of a trapezium.

(20) In some embodiments, the acoustic wave device **1** may be used to process acoustic signals with a wavelength  $\lambda$ . In some embodiments, the distance **d1** may be in the range of 5% to 10% of the wavelength  $\lambda$ , such that the metal fill **151** do not contact the electrode **131** or the bus bar **122**, so as to prevent a short circuit from being formed between the metal fill **151** and the electrode **131**, and/or between the metal fill **151** and the bus bar **122**. Furthermore, the thickness **d2** may be related to the wavelength  $\lambda$ . For example, the thickness **d2** may be 2%-6% of the wavelength  $\lambda$ , such as 4% of the wavelength  $\lambda$ , so as to effect favorably to block the acoustic signal from transmitting along the direction **D1**. For example, the wavelength  $\lambda$  may be 2  $\mu\text{m}$ , the distance **d1** may be between 0.1  $\mu\text{m}$  and 0.2  $\mu\text{m}$ , and the thickness **d2** may be equal to 0.08  $\mu\text{m}$ .

(21) In FIGS. 2A to 2C, the edge **122e** of the bus bar **122** may be, but is not limited to, continuously joined to the second sidewall **w2** of the depression **21**. FIG. 3 is a schematic diagram of the depression **21** of the acoustic wave device **1** according to another embodiment of the invention, and may be used to replace the depressions **21** in FIGS. 2A to 2C. In FIG. 3, the edge **122e** of the bus bar **122** and the second sidewall **w2** of the depression **21** may not be continuously joined. For example, the edge **122e** of the bus bar **122** and the second sidewall **w2** of the depression **21** may form a step at the surface **101** of the piezoelectric substrate **10**. Specifically, the depression **21** may have a size **d5** along the direction **D1** at the surface **101** of the piezoelectric substrate **10**, and the size **d5** may be less than the top size **d3** along the direction **D1** of the first gap, and/or equal to a bottom size **d6** along the direction **D1** of the depression **21**. The configuration of the metal fill **151** in FIG. 3 is similar to that in FIG. 2A, and the explanation therefor will not be repeated here.

(22) The configuration of the metal fill **161** and the depression **31** will be explained in detail in the subsequent paragraphs, and the configuration of other metal fills and depressions may be similar, and explanation therefor will be omitted for brevity. FIGS. 4A to 4C show cross-sectional views of the acoustic wave device **1** along Line 4-4'. The electrode **141** may have a size **d7** along the direction **D2**, and the depression **31** may have a size **d8** along the direction **D2**. The size **d8** of the

depression **31** may be equal to (FIG. 4A), smaller (FIG. 4C), or larger (FIG. 4B) than the size **d7** of the electrode **141**. The larger the size **d8** is, the larger the volume of the metal fill **161** may be and the heavier weight load is. Therefore, the quality factor of the acoustic wave device **1** is enhanced.

(23) FIG. 5 is a top view of an acoustic wave device **5** according to another embodiment of the invention. The acoustic wave device **5** may include the piezoelectric substrate **10**, a transducer **51**, depressions **21** to **23** and **31** to **33**, and metal fills **151** to **153** and **161** to **163**. The acoustic wave device **5** and the acoustic wave device **1** are different in that the transducer **51** further includes dummy electrodes **171** to **173** and dummy electrodes **181** to **183**. The dummy electrodes **171** to **173** have dummy ends **171e** to **173e**, respectively, and may extend from the bus bar **122** to the dummy ends **171e** to **173e** along the direction **D1**, respectively. The dummy electrodes **181** to **183** have dummy ends **181e** to **183e**, respectively, and may extend from the bus bar **121** to the dummy ends **181e** to **183e** along the direction **D1**, respectively. The dummy ends **171e** to **173e** of the dummy electrodes **171** to **173** may be aligned along the direction **D1** with the ends **131e** to **133e** of the electrodes **131** to **133**, respectively, and the dummy ends **181e** to **183e** of the dummy electrodes **181** to **183** may be aligned along the direction **D1** with the ends **141e** to **143e** of the electrodes **141** to **143**, respectively. Further, the dummy ends **171e** to **173e** may be aligned with each other along the direction **D2**, and the dummy ends **181e** to **183e** may be aligned with each other along the direction **D2**. In FIG. 5, the first gaps may be formed between the ends **131e** to **133e** of the electrodes **131** to **133** and the dummy ends **171e** to **173e** of the dummy electrodes **171** to **173**, respectively, and the second gaps may be formed between the ends **141e** to **143e** of the electrodes **141** to **143** and the dummy ends **181e** to **183e** of the dummy electrodes **181** to **183**, respectively.

(24) In the acoustic wave device **5**, for example, the end **131e** of the electrode **131** may be continuously joined to the first sidewall of the depression **21** along the direction **D3**. Further, the dummy end **171e** of the dummy electrode **171** may be continuously joined to the second sidewall of the depression **21**. Similarly, the end **141e** of the electrode **141** may be continuously joined to the third sidewall of the depression **31**. Furthermore, the dummy end **181e** of the dummy electrode **181** may be continuously joined to the fourth sidewall of the depression **31**. The ratio of the top size of the first gap along the direction **D1** to the bottom size of the depression **21** along the direction **D1** may be between 0.8 and 1.2, and the ratio of the top size of the second gap along the direction **D1** to the bottom size of the depression **31** along the direction **D1** may be between 0.8 and 1.2.

(25) In the acoustic wave device **5**, energy leakage of the acoustic signal along the direction **D1** may be further reduced by disposing the dummy electrodes **171** to **173** and/or **181** to **183**, thereby further enhancing the quality factor of the acoustic wave device **5**. In some embodiments, the materials of the dummy electrodes **171** to **173** and/or **181** to **183** include a metal, and the metal may be selected from at least one of the following: molybdenum (Mo), copper (Cu), aluminum (Al), gold (Au), platinum (Pt), tungsten (W), and a combination thereof.

(26) For the acoustic wave devices **1** and **5**, those skilled in the art may also adjust the number of electrodes **131-133** and/or the number of electrodes **141-143** to meet various application requirements without deviating from the principles of the invention.

(27) FIGS. 6 to 8 show schematic diagrams of a method of fabricating the acoustic wave device. FIG. 6 shows a piezoelectric substrate **10** and a conductive layer disposed on the surface of the piezoelectric substrate **10**. The conductive layer may be patterned by ways of a patterning method to a form patterned conductive layer. In some embodiments, the patterned conductive layer may include the bus bar **121**, the electrode **131**, and the bus bar **122**. Further, the patterned conductive layer may include a pad **60**. FIGS. 6 to 8 show an exemplary structure of the transducer, and the patterned conductive layer may further include other structures.

(28) In some embodiments, as in FIG. 7, the depression **21** may be formed in the piezoelectric substrate **10**, and the depression **21** is depressed from the surface **101** of the piezoelectric substrate **10**. The first sidewall **w1** of the depression **21** may be continuously joined to the end **131e** of the electrode **131**, and the second sidewall **w2** of the depression **21** may be continuously joined to the

edge **122e** of the bus bar **122**.

(29) In some embodiments, as in FIG. **8**, the depression **21** is filled with the metal fill **151** which has the metal fill surface **1511**. The distance between the surface **101** of the piezoelectric substrate **10** and the metal fill surface **1511** in the direction **D3** is greater than zero.

(30) In some embodiments, as in FIGS. **6** to **8**, the method further includes forming a bridge layer **62**. The bridge **62** may be at least partially located between the pad **60** and the bus bar **121**. A connection layer **64** is formed to provide connection from the electrode **131**, the bus bar **121**, and/or the bus bar **122** to an external circuit.

(31) In some embodiments, as in FIG. **8**, the method further includes forming an insulating layer **80** to protect the acoustic wave device.

(32) FIG. **9** is a flowchart of the method **900** of fabricating the acoustic wave device **1** or **5**. The method **900** includes Steps **S902** to **S916** for fabricating the acoustic wave device **1** or **5**. Any reasonable step change or adjustment is within the scope of the present disclosure. Steps **S902** to **S916** are detailed as follows:

(33) Step **S902**: Provide a piezoelectric substrate **10**;

(34) Step **S904**: Form a conductive layer on the surface **101** of the piezoelectric substrate **10**;

(35) Step **S906**: Pattern the conductive layer with a photomask to form the patterned conductive layer, the patterned conductive layer may include the pad **60**, the bus bar **121**, the electrode **131**, and the bus bar **122**;

(36) Step **S908**: Form the depression **21** in the piezoelectric substrate **10**, the depression **21** is depressed from the surface **101** of the piezoelectric substrate **10**, and the first sidewall **w1** of the depression **21** is continuously joined to the end **131e** of the electrode **131** in the direction **D3**;

(37) Step **S910**: Fill the depression **21** with a metallic material to form the metal fill **151**;

(38) Step **S912**: Form the bridge layer **62**, the bridge layer **62** may be at least partially located between the pad **60** and the bus bar **121**;

(39) Step **S914**: Form the connection layer **64**, and the connection layer **64** is used to provide connections from the electrode **131**, the bus bar **121**, and/or the bus bar **122** to the external circuit;

(40) Step **S916**: Form the insulating layer **80**, the insulating layer **80** may be located above the pad **60**, the connection layer **64**, the bridge layer **62**, the electrode **131**, the metal fill **151** and the bus bar **122**.

(41) Referring to FIG. **6**, in some embodiments, in Step **S906**, the pad **60**, the bus bar **121**, the electrode **131**, and the bus bar **122** may be formed simultaneously in the patterned conductive layer. In other embodiments, the dummy electrodes electrically connected to the bus bar **122** may also be formed. Referring to FIG. **7**, in Step **S908**, the depression **21** may be formed by an etching process using a photomask. Referring to FIG. **8**, in Step **S910**, the metal **Mo** may be used to form the metal fill **151** in the depression **21**. The thickness of the metal fill **151** and the thickness of the patterned conductive layer may be equal or different.

(42) Those skilled in the art will readily observe that numerous modifications and alterations of the device and method may be made while retaining the teachings of the invention. Accordingly, the above disclosure should be construed as limited only by the metes and bounds of the appended claims.

## Claims

1. An acoustic wave device comprising: a piezoelectric substrate having a first surface; a transducer disposed on the first surface of the piezoelectric substrate, the transducer comprising: a first bus bar extending along a second direction; a first electrode having a first end, and extending from the first bus bar to the first end along a first direction; a second bus bar extending along the second direction; and a second electrode having a second end and extending from the second bus bar to the second end along the first direction, wherein the second electrode and the first electrode is spaced



apart in the second direction, and a first gap is formed between the first end of the first electrode and an edge of the second bus bar; and a first depression formed in the piezoelectric substrate and depressed from the first surface of the piezoelectric substrate, wherein the first depression has a first sidewall, and the first end of the first electrode is continuously joined to the first sidewall of the first depression in a depth direction.

2. The acoustic wave device of claim 1, wherein: the first depression further has a second sidewall; the edge of the second bus bar is continuously joined to the second sidewall of the first depression in the depth direction; and a ratio of a top size of the first gap along the first direction to a bottom size of the first depression along the first direction is between 0.8 and 1.2.

3. The acoustic wave device of claim 1, further comprising: a first metal fill filled in the first depression of the piezoelectric substrate, wherein the first metal fill has a first metal fill surface, and wherein a first distance between the first surface and the first metal fill surfaces in the depth direction is greater than 0.

4. The acoustic wave device of claim 1, wherein: a second gap is formed between the second end of the second electrode and an edge of the first bus bar; and the acoustic wave device further comprises: a second depression formed in the piezoelectric substrate and depressed from the first surface of the piezoelectric substrate, wherein the second depression has a third sidewall, and the second end of the second electrode is continuously joined to the third sidewall of the second depression in the depth direction.

5. The acoustic wave device of claim 4, wherein: the first depression further has a second sidewall; the second depression further has a fourth sidewall; in the depth direction, the edge of the second bus bar is continuously joined to the second sidewall of the first depression, and the edge of the first bus bar is continuously joined to the fourth sidewall of the second depression; and a ratio of a top size of the first gap along the first direction to a bottom size of the first depression along the first direction is between 0.8 and 1.2, and a ratio of a top size of the second gap along the first direction to a bottom size of the second depression along the first direction is between 0.8 and 1.2.

6. The acoustic wave device of claim 4, wherein: the transducer further comprises: a first dummy electrode extending from the second bus bar along the first direction, and having a first dummy end, wherein the first dummy end of the first dummy electrode is aligned with the first end of the first electrode along the first direction; and a second dummy electrode extending from the first bus bar along the first direction, and having a second dummy end, wherein the second dummy end of the second dummy electrode is aligned with the second end of the second electrode along the first direction; wherein the first gap is formed between the first end of the first electrode and the first dummy end of the first dummy electrode; and the second gap is formed between the second end of the second electrode and the second dummy end of the second dummy electrode.

7. The acoustic wave device of claim 6, wherein: the first depression further has a second sidewall; the second depression further has a fourth sidewall; in the depth direction, the first dummy end of the first dummy electrode is continuously joined to the second sidewall of the first depression, and the second dummy end of the second dummy electrode is continuously joined to the fourth sidewall of the second depression; and a ratio of a top size of the first gap along the first direction to a bottom size of the first depression along the first direction is between 0.8 and 1.2, and a ratio of a top size of the second gap along the first direction to a bottom size of the second depression along the first direction is between 0.8 and 1.2.

8. The acoustic wave device of claim 4, further comprising: a first metal fill filled in the first depression of the piezoelectric substrate, the first metal fill having a first metal fill surface; and a second metal fill filled in the second depression of the piezoelectric substrate, the second metal fill having a second metal fill surface; wherein in the depth direction, a first distance between the first surface and the first metal fill surface is greater than 0, and a second distance between the first surface and the second metal fill surface is greater than 0.

9. The acoustic wave device of claim 8, wherein the first distance is equal to the second distance.

10. The acoustic wave device of claim 8, wherein: the acoustic wave device is used to process an acoustic wave having a wavelength; a first thickness of the first metal fill along the depth direction is 2% to 6% of the wavelength; and a second thickness of the second metal fill along the depth direction is 2% to 6% of the wavelength.
11. The acoustic wave device of claim 8, wherein: the acoustic wave device is used to process an acoustic wave having a wavelength; the first distance is ranged between 5% and 10% of the wavelength; and the second distance is ranged between 5% and 10% of the wavelength.
12. The acoustic wave device of claim 1, wherein the second direction is perpendicular to the first direction.
13. The acoustic wave device of claim 1, wherein materials of the first electrode, the second electrode, the first bus bar, and the second bus bar comprises a metal, and the metal is selected from at least one of molybdenum (Mo), copper (Cu), aluminum (Al), gold (Au), platinum (Pt), tungsten (W), and a combination thereof.
14. The acoustic wave device of claim 1, wherein a size of the first depression along the second direction is equal to, less than, or greater than a size of the first electrode along the second direction.
15. The acoustic wave device of claim 1, wherein the first electrode is parallel to the second electrode, and the first bus bar is parallel to the second bus bar.
16. A method of fabricating an acoustic wave device, the method comprising: providing a piezoelectric substrate, the piezoelectric substrate having a first surface; forming a conductive layer on the first surface; patterning the conductive layer to form a patterned conductive layer, wherein the patterned conductive layer comprises: a first bus bar extending along a second direction; a first electrode having a first end and extending from the first bus bar to the first end along a first direction; a second bus bar extending along the second direction; and a second electrode having a second end and extending from the second bus bar to the second end along the first direction, wherein the second electrode and the first electrode is spaced apart in the second direction, and a first gap is formed between the first end of the first electrode and an edge of the second bus bar; and forming a first depression in the piezoelectric substrate, wherein the first depression is depressed from the first surface of the piezoelectric substrate, the first depression has a first sidewall, and the first end of the first electrode is continuously joined to the first sidewall of the first depression in a depth direction.
17. The method of claim 16, further comprising: filling a first metal fill in the first depression, wherein the first metal fill has a first metal fill surface, and a first distance between the first surface and the first metal fill surface in the depth direction is greater than 0.
18. The method of claim 17, wherein: the patterned conductive layer further comprises: a first dummy electrode extending from the second bus bar along the first direction and having a first dummy end, wherein the first dummy end of the first dummy electrode is aligned with the first end of the first electrode along the first direction; and a second dummy electrode extending from the first bus bar along the first direction and having a second dummy end, wherein the second dummy end of the second dummy electrode is aligned with the second end of the second electrode along the first direction, and wherein the first gap is formed between the first end of the first electrode and the first dummy end of the first dummy electrode, and a second gap is formed between the second end of the second electrode and the second dummy end of the second dummy electrode; the method further comprises: forming a second depression in the piezoelectric substrate, wherein the second depression is depressed from the first surface of the piezoelectric substrate, the second depression has a third sidewall, and the second end of the second electrode is continuously joined to the third sidewall of the second depression in a depth direction; and filling a second metal fill in the second depression, the second metal fill having a second metal fill surface, and a second distance between the second surface and the second metal fill surface in the depth direction is greater than 0.

19. The method of claim 18, wherein: the first depression further has a second sidewall; the second depression further has a fourth sidewall; the first dummy end of the first dummy electrode is continuously joined to the second sidewall of the first depression in the depth direction; the second dummy end of the second dummy electrode is continuously joined to the fourth sidewall of the second depression; and a ratio of a top size of the first gap along the first direction to a bottom size of the first depression along the first direction is between 0.8 and 1.2, and a ratio of a top size of the second gap along the first direction to a bottom size of the second depression along the first direction is between 0.8 and 1.2.

20. The method of claim 18, wherein: the first metal fill has a first metal fill surface; and the second fill metal has a second fill metal surface; and wherein in the depth direction, a first distance between the first surface and the first metal fill surface is greater than 0, and a second distance between the first surface and the second metal fill surface is greater than 0.

---